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	Kuo-Yu Chou . Tong-Chern Ong			V GCI	Gray had	Richard	
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TERMINAL		DRAWINGS			CLAIMS ALLOWED		
	DISCLAIMER	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G	
The term of this patent subsequent to (date) has been disclaimed.					NOTICE OF ALI	OWANCE MAILED	
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	The term of this patent shall not extend beyond the expiration date						
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